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# From insulator to oxide-ion conductor by a synergistic effect from defect chemistry and microstructure: acceptor-doped Bi-excess sodium bismuth titanate $\text{Na}_{0.5}\text{Bi}_{0.51}\text{TiO}_{3.015}$ †

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The influence of Ti-site acceptor-doping ( $\text{Mg}^{2+}$ ,  $\text{Zn}^{2+}$ ,  $\text{Sc}^{3+}$ ,  $\text{Ga}^{3+}$  and  $\text{Al}^{3+}$ ) on the electrical conductivity and conduction mechanism of a nominally Bi-excess sodium bismuth titanate perovskite,  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{TiO}_{3.015}$  ( $\text{NB}_{0.51}\text{T}$ ), is reported. Low levels of acceptor-type dopants can introduce appreciable levels of oxide-ion conductivity into  $\text{NB}_{0.51}\text{T}$ , *i.e.*, 0.5% Mg-doping for  $\text{Ti}^{4+}$  can enhance the bulk conductivity of  $\text{NB}_{0.51}\text{T}$  by more than 3 orders of magnitude with the oxide-ion transport number going from  $<0.1$  for  $\text{NB}_{0.51}\text{T}$  to  $>0.9$  at 600 °C. The intriguing electrical behaviour in acceptor-doped  $\text{NB}_{0.51}\text{T}$  dielectrics is a synergistic effect based on the defect chemistry and ceramic microstructure in these materials.  $\text{NB}_{0.51}\text{T}$  ceramics with extremely low levels of doping show an inhomogeneous microstructure with randomly distributed large grains embedded in a small grained matrix. This can be considered as a two-phase composite with large grains as a conductive phase and small grains as an insulating phase based on an empirical conductivity – grain size relationship. Variation in the fraction of the conductive, large grained phase with increasing doping levels agrees with the oxide-ion transport number. This electrical two-phase model is supported by finite element modelling. This study reveals the significance of ceramic microstructure on the electrical conduction behaviour of these materials and can provide a guideline for selecting suitable doping strategies to meet the electrical property requirements of NBT-based ceramics for different applications.

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## Introduction

Sodium bismuth titanate,  $\text{Na}_{0.5}\text{Bi}_{0.5}\text{TiO}_3$  (NBT), can present three types of electrical behaviour by varying the A-site Bi content: (1) type I, oxide-ion conduction occurs in nominally stoichiometric NBT ( $\text{NB}_{0.50}\text{T}$ ) and Bi-deficient NBT (*i.e.*,  $\text{Na}_{0.5}\text{Bi}_{0.49}\text{TiO}_{2.985}$ ,  $\text{NB}_{0.49}\text{T}$ ), with high bulk conductivities and oxide-ion transport numbers close to unity, *i.e.*  $\sigma_b > 10^{-3} \text{ S cm}^{-1}$  and  $t_{\text{ion}} > 0.9$  at 600 °C;<sup>1</sup> (2) type II, mixed ionic–electronic conduction is observed in NBT with high levels of Bi excess (*i.e.*,  $\text{Na}_{0.5}\text{Bi}_{0.52}\text{TiO}_{3.03}$ ,  $\text{NB}_{0.52}\text{T}$ ), with intermediate magnitude of  $\sigma_b$  ( $\sim 10^{-5} \text{ S cm}^{-1}$ , 600 °C) and  $t_{\text{ion}} \sim 0.5$ ;<sup>2</sup> (3) type III, electrically insulating behaviour exists in slightly Bi-excess NBT (*i.e.*,  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{TiO}_{3.015}$ ,  $\text{NB}_{0.51}\text{T}$ ), with very low  $\sigma_b$  and  $t_{\text{ion}}$  close to

zero, *i.e.*  $\sigma_b \sim 10^{-6} \text{ S cm}^{-1}$  and  $t_{\text{ion}} = 0.07$ , 600 °C.<sup>1</sup> The diverse and tunable electrical properties make NBT-based materials promising candidates for applications in many important energy devices. For example, as electrolyte/electrode materials in intermediate-temperature solid oxide fuel cells (IT-SOFCs) and as high-permittivity dielectrics for multilayer ceramic capacitors (MLCCs).

The flexible electrical conduction behaviour is attributed to the high mobility of oxygen ions in the NBT lattice as the highly polarisable  $\text{Bi}^{3+}$  ions with their  $6s^2$  lone-pair electrons and weak Bi–O bonds provide pathways with low diffusion barriers for oxygen ion migration.<sup>3</sup> A small number of oxygen vacancies can introduce a significant level of oxide-ion conduction into NBT according to  $\sigma = c \times q \times \mu$ , where  $c$ ,  $q$  and  $\mu$  represent the concentration, charge and mobility of oxygen ions, respectively. For example, 0.25–0.5% oxygen deficiency, corresponding to an oxygen vacancy concentration of 0.083–0.167%, in the nominally stoichiometric  $\text{NB}_{0.50}\text{T}$  caused by “accidental”  $\text{Bi}_2\text{O}_3$ -loss during ceramic processing,<sup>4</sup> results in high conductivity of  $\sim 10^{-3} \text{ S cm}^{-1}$  at 600 °C. Tuning the conductivity and conduction mechanism among types I, II and III can therefore be achieved by various defect mechanisms such as A-site

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nonstoichiometry, acceptor- and donor-doping to manipulate the concentration of oxygen vacancies in NBT. In general, using the oxide-ion conducting  $\text{NB}_{0.50}\text{T}$  as a reference, defect mechanisms that introduce additional oxygen vacancies, *i.e.*, Bi-deficiency and acceptor-doping, can enhance  $\sigma_b$  by increasing the charge carrier concentration; on the contrary, defect mechanisms that reduce the concentration of oxygen vacancies, *i.e.*, B-site Nb (donor) doping, suppress the contribution of oxide-ion conduction to  $\sigma_b$ , and switch the electrical behaviour from type I to type II when oxygen vacancies are partially filled, and to type III when the oxygen vacancy concentration is minimal. A detailed review of the defect chemistry-electrical property relationships of NBT can be found elsewhere.<sup>5</sup>

Apart from the above-mentioned magnitudes of  $\sigma_b$  and  $t_{\text{ion}}$ , the three types of electrical behaviour of undoped and doped NBTs can also be identified by the following empirical, indirect criteria: (1) oxygen nonstoichiometry. As the presence of oxygen vacancies is the pre-requisite for the oxide-ion conduction, NBT with a nominal composition that is oxygen deficient is likely to be oxide-ion conducting (type I). On the contrary, NBT with a nominal oxygen-excess composition is likely to be insulating (type III) or mixed conducting (type II). Caution should be made regarding the nominally oxygen-stoichiometric NBTs, which can be type I (*e.g.*,  $\text{NB}_{0.50}\text{T}$ ), type II (*e.g.*,  $(\text{NB}_{0.50}\text{T})_{0.8}(\text{BiScO}_3)_{0.2}$  solid solution<sup>6</sup>) and type III (*e.g.*,  $(\text{NB}_{0.50}\text{T})_{0.93}(\text{BiAlO}_3)_{0.07}$  solid solution<sup>7</sup>). (2) Dielectric loss-temperature profile ( $\tan \delta - T$ , 1 MHz). Type I NBT exhibit a rapid increase in  $\tan \delta$  with increasing temperature from  $\sim 0.02$  at room temperature to  $> 0.2$  at  $\sim 300$ – $400$  °C. In contrast,  $\tan \delta$  of type III NBT initially decreases with increasing temperature and retain very low values of  $\sim 0.005$  over a temperature range between  $300$ – $600$  °C and then show a rapid increase at higher temperatures. Type II NBT have similar  $\tan \delta - T$  profiles as type III in the low temperature ranges ( $< 300$  °C) but with an onset temperature for the rapid increase of  $\tan \delta$  between  $300$ – $600$  °C. (3) Activation energy,  $E_a$ , of the bulk conductivity. One of the characteristic features on the  $\sigma_b$  Arrhenius plot of type I NBT is a change in  $E_a$  from  $\sim 0.85$  eV below  $300$  °C to  $\sim 0.45$  eV above  $300$  °C, which may be related to the coexistence of the rhombohedral and tetragonal polymorphs of NBT,<sup>8</sup> or a combination of dissociation of defect clusters and different conduction paths in the various polymorphs.<sup>9</sup> Type III NBT usually have  $E_a \sim 1.6$  eV at  $500$ – $800$  °C ( $E_a$  in the low temperature range is unknown as the conductivity is too low to be measured below  $500$  °C). Type II NBT usually display  $E_a$  between  $1.0$ – $1.6$  eV at  $T > 500$  °C. (4) Microstructure. At the same sintering temperature (*i.e.*,  $1150$  °C), type I NBT ceramics usually show much larger grains ( $\sim 10$ – $20$   $\mu\text{m}$  for  $\text{NB}_{0.50}\text{T}$ ) than type III NBT ( $< 5$   $\mu\text{m}$ ).<sup>1</sup> Significant variations in average grain size of type I, II and III NBT ceramics are also reported for the  $(\text{NB}_{0.50}\text{T})_{1-x}(\text{BiAlO}_3)_x$  solid solution<sup>7</sup> and Nb-doped  $\text{NB}_{0.50}\text{T}$ ,  $(\text{Na}_{0.5}\text{Bi}_{0.5}\text{Ti}_{1-y}\text{Nb}_y\text{O}_{3+0.5y})$ ,<sup>2</sup> in which the average grain size decreases with decreasing  $t_{\text{ion}}$ . This is not surprising as grain growth during sintering is a diffusion-controlled process, and the diffusion coefficient is proportional to the ionic conductivity according to Nernst–Einstein equation.

Since the discovery of high levels of oxide-ion conduction in NBT in 2014, there has been substantial efforts to enhance the bulk conductivity by incorporating acceptor-type dopants into  $\text{NB}_{0.50}\text{T}$  and  $\text{NB}_{0.49}\text{T}$  (type I). For example,  $\text{Li}^+$ ,  $\text{Na}^+$ ,  $\text{Ca}^{2+}$ ,  $\text{Sr}^{2+}$  and  $\text{Ba}^{2+}$  are introduced to partially replace  $\text{Bi}^{3+}$  on the A-site;<sup>8,10–13</sup>  $\text{Mg}^{2+}$ ,  $\text{Zn}^{2+}$ ,  $\text{Al}^{3+}$ ,  $\text{Sc}^{3+}$  and  $\text{Ga}^{3+}$  to partially replace  $\text{Ti}^{4+}$  on the B-site.<sup>1,10,14–18</sup> Detailed discussions on the defect chemistry induced by these acceptor dopants can be found in ref. 5 and 12. In all these cases, the lower positive charge caused by the acceptor dopants is compensated (ionically) by creation of oxygen vacancies. With the above attempts,  $\sigma_b$  is enhanced by  $\sim 1$  order of magnitude compared to  $\text{NB}_{0.50}\text{T}$  and  $\sim$  half an order of magnitude compared to  $\text{NB}_{0.49}\text{T}$  due to an increase in the oxygen vacancy concentration. An optimised  $\sigma_b$  is achieved using either A-site Sr-doping or B-site Mg-doping in  $\text{NB}_{0.49}\text{T}$ , with  $\sigma_b$  approaching  $10^{-2}$   $\text{S cm}^{-1}$  and  $t_{\text{ion}} > 0.95$  at  $600$  °C. Such a conductivity maximum is consistent with the oxygen vacancy diffusivity limit model in a perovskite lattice as proposed by R. A. De Souza.<sup>19</sup>

Here we investigate the effect of acceptor-doping on the electrical properties of a Bi-excess NBT,  $\text{NB}_{0.51}\text{T}$  (type III), based on the following considerations. (1) Acceptor-doping such as  $\text{Mg}^{2+}$  and  $\text{Sc}^{3+}$  on the Ti-site will give nominal chemical formulae of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  and  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-y}\text{Sc}_y\text{O}_{3.015-0.5y}$ , respectively. According to the previously mentioned empirical relationship between conductivity and oxygen nonstoichiometry, we would expect compositional ranges of  $0 < x < 0.015$  and  $0 < y < 0.03$  whereby the ceramics remain electrically insulating. This may facilitate fine tuning of the material properties by acceptor-doping without a significant increase in the dielectric loss/leaky current, which may be useful for its application as a dielectric and piezo/ferroelectric. (2) According to molecular dynamics (MD) and molecular static (MS) simulations,<sup>20</sup> A-site Bi vacancies are detrimental to diffusion of oxygen ions.  $\text{NB}_{0.50}\text{T}$  and  $\text{NB}_{0.49}\text{T}$  both have Bi vacancies due to either Bi loss during ceramic processing or intentional design to have a nominal Bi deficiency. It is therefore a curiosity to explore whether higher oxide-ion conductivity can be achieved in  $\text{NB}_{0.51}\text{T}$ , in which the A-site is nominally fully occupied, by acceptor doping on the Ti-site with appropriate levels of doping. (3) As  $\text{NB}_{0.50}\text{T}$  and  $\text{NB}_{0.49}\text{T}$  already have high oxide-ion conductivity, enhancement of conductivity by acceptor doping is quite limited. The bulk conductivities of these acceptor-doped NBT are all within a narrow range on the  $\sigma_b$  Arrhenius plot,<sup>10</sup> which makes it difficult to compare the impact of different dopants. Acceptor-doping in  $\text{NB}_{0.51}\text{T}$  may induce a significant change in  $\sigma_b$  by several orders of magnitude. It is therefore of interest to investigate the difference among various dopants to provide a criterion for dopant selection.

Based on the reasoning above, we select various acceptor-type ions, including divalent  $\text{Mg}^{2+}$  and  $\text{Zn}^{2+}$ , trivalent  $\text{Al}^{3+}$ ,  $\text{Sc}^{3+}$  and  $\text{Ga}^{3+}$ , to partially replace Ti on the B-site of  $\text{NB}_{0.51}\text{T}$ . The electrical properties of these acceptor-doped  $\text{NB}_{0.51}\text{T}$  ceramics are established by a combination of impedance spectroscopy and electromotive force transport number measurements. It is surprising to find that extremely low levels of acceptor dopants

(*i.e.*, <0.5% for divalent ions) can introduce significant levels of oxide ion conduction into  $\text{NB}_{0.51}\text{T}$  and change the conduction mechanism from insulating to ionic-conducting based on  $t_{\text{ion}}$  (*i.e.*,  $t_{\text{ion}} > 0.9$  for 0.25% Mg-doped  $\text{NB}_{0.51}\text{T}$ ). In contrast to  $\text{NB}_{0.50}\text{T}$  and  $\text{NB}_{0.49}\text{T}$ , we demonstrate that acceptor-doping in  $\text{NB}_{0.51}\text{T}$  is a synergistic effect based on a combination of defect chemistry and ceramic microstructure.  $\text{NB}_{0.51}\text{T}$  ceramics with extremely low doping levels exhibit inhomogeneous microstructures with randomly distributed large grains embedded in a small grained matrix. They can be considered (electrically) as a two-phase composite with the large grains being a conductive phase and the small grains being an insulating phase based on an empirical conductivity – grain size relationship. Finite element modelling is used to support this two-phase model. The formation mechanism of this inhomogeneous grain structure is not known but we suggest it is linked to the lack of homogenisation on acceptor-doping at such low levels during solid state synthesis. This can result in large conductive grains that are acceptor-rich and smaller grains that are acceptor-deficient or undoped. Analytical SEM is unable to detect the small variations in the level of dopants required to induce this effect; however, the grain size variations and electrical conductivity of NBT are sensitive to small levels of compositional variation. This work reveals the significance of ceramic microstructure on the electrical properties of NBT-based materials and can provide guidelines for selecting appropriate doping strategies to meet the electrical property requirements for different applications.

## Experimental

Acceptor-doped  $\text{NB}_{0.51}\text{T}$  ceramics, with chemical formulae of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{M}_x\text{O}_{3.015-x}$  ( $\text{M} = \text{Mg}$  and  $\text{Zn}$ ) and  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-y}\text{N}_y\text{O}_{3.015-0.5y}$  ( $\text{N} = \text{Sc}$ ,  $\text{Al}$  and  $\text{Ga}$ ) were prepared by a solid state reaction method using  $\text{Na}_2\text{CO}_3$  (99.5%, Fisher Chemical, UK),  $\text{Bi}_2\text{O}_3$  (99.9%, Acros Organics, USA),  $\text{TiO}_2$  (99.9%, Sigma Aldrich, UK),  $\text{MgO}$  (99.9%, Alfa Aesar, UK),  $\text{ZnO}$  (99.9%, Fluka, UK),  $\text{Sc}_2\text{O}_3$  (99.99%, Stanford Materials, USA),  $\text{Al}_2\text{O}_3$  (99.95%, Alfa Aesar, UK) and  $\text{Ga}_2\text{O}_3$  (99.9%, Sigma Aldrich, UK) as starting materials. Prior to weighing, the raw powders were dried overnight at 300 °C for  $\text{Na}_2\text{CO}_3$  and  $\text{Bi}_2\text{O}_3$ , 600 °C for  $\text{ZnO}$  and  $\text{Ga}_2\text{O}_3$ , and 900 °C for  $\text{TiO}_2$ ,  $\text{MgO}$ ,  $\text{Sc}_2\text{O}_3$  and  $\text{Al}_2\text{O}_3$ . Appropriate amounts of each precursor were weighed and ball-milled in iso-propanol using yttria-stabilised zirconia grinding media for 6 hours. The mixture was dried overnight in an 85 °C oven, sieved and then calcined at 800 °C for 2 hours. The resultant powders were subjected to a second round of ball milling, drying, sieving and calcination and subsequently to a final, third round of ball milling and sieving. The products were compacted into pellets by uni-axial cold pressing followed by isostatic pressing at 200 MPa. Pellets were embedded in sacrificial powder of the same composition and sintered at 1150 °C for 2 hours. After sintering, pellets were removed from the sacrificial powder and ground using SiC sand papers to obtain flat surfaces.

Phase purity was examined by X-ray diffraction on the pellet surface using a Bruker D2 phaser or on crushed pellets using

a high-resolution STOE STADI-P diffractometer. Ceramic microstructures were observed by scanning electron microscopy (SEM, JEOL JSM-6010LA, JEOL Ltd., Tokyo, Japan) on thermally etched surfaces. The grain size distribution of each ceramic was measured from the SEM images using ImageJ software. Compositions were analysed by energy-dispersive X-ray spectroscopy (EDS) on 5–10 randomly selected areas on the carbon-coated polished surfaces (without thermal etch).

Electrical properties were measured by impedance spectroscopy using an Agilent E4980A impedance analyser (Agilent Technologies Inc., Palo-Alto, CA; frequency range 1 MHz to 20 Hz) or a Solartron 1260 system (Solartron Analytical, UK; frequency range 1 MHz to 20 Hz) using Au paste (fired at 850 °C for 2 h) as electrodes. All impedance data were corrected for high frequency inductance associated with the leads and the measurement jig by performing a short circuit measurement and normalised by a geometric factor (thickness/surface area). Equivalent circuit fitting was performed using ZView software (Scribner Associates, Inc, Southern Pines, NC). Dielectric properties were measured using an LCR meter (Agilent E4980 Precision LCR Meter, Agilent Technologies) with an applied *ac* voltage of 100 mV. Data points were collected every 60 s from room temperature (RT) to 800 °C using a non-inductively wound tube furnace at a ramp rate of 1 °C min<sup>-1</sup>. Oxygen-ion transport number measurements were performed using a ProboStat™ system (NorECs Norwegian Electro Ceramics AS, Oslo, Norway). Details of the measurement can be found in previous publications.<sup>1,7</sup>

To study how materials properties (conductivity and permittivity) and a collection of non-uniform grains influence the electrical response we use an in-house developed FEM package, ElCer, to simulate the electrical response of electroceramics.<sup>21</sup> The models are first constructed using 3D Voronoi tessellation. Each volume, representing a grain, is then meshed and assigned its own conductivity and permittivity value. ElCer is then used to solve the complete electrical response of the system through Maxwell's equations and the response converted into an impedance spectrum that can be analysed and compared to experimental results.

## Results

### Phase, microstructure, and composition

$\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ( $x = 0, 0.001, 0.0025, 0.005, 0.01, 0.015$  and  $0.02$ ) ceramics are phase-pure based on laboratory XRD (Fig. 1a). An expanded view of the  $2\theta$  range between 37 and 42° shows the superlattice reflection of a rhombohedral structure for all compositions (Fig. 1b). XRD patterns for other acceptor-doped  $\text{NB}_{0.51}\text{T}$  are given in ESI (Fig. S1–S3† for Sc, Al and Ga-doping, respectively).

SEM images of thermally-etched surfaces of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ceramics with selected compositions are presented in Fig. 2, where apparent grain growth can be observed with increasing  $x$ . Undoped  $\text{NB}_{0.51}\text{T}$  ceramics have uniform, small grains with an average grain size of  $\sim 1\text{--}2$   $\mu\text{m}$  (Fig. S4†). With extremely low levels of Mg-doping (*i.e.*,  $x = 0.001$ , Fig. 2a), ceramics show an inhomogeneous microstructure with a small



Fig. 1 (a) Room temperature XRD patterns of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ( $x = 0, 0.001, 0.0025, 0.005, 0.01, 0.015$  and  $0.02$ ) ceramics and (b) an expanded view of the  $2\theta$  range between  $37$  and  $42^\circ$  showing the superlattice reflection of the rhombohedral structure as indicated by the arrow.



Fig. 2 SEM micrographs of thermally-etched surfaces of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ceramics. (a)  $x = 0.001$ ; (b)  $x = 0.0025$ ; (c)  $x = 0.005$ ; (d)  $x = 0.01$ .

number of large grains ( $\sim 5\text{--}10\ \mu\text{m}$ ) randomly distributed in a small grained ( $\sim 2\ \mu\text{m}$ ) matrix. With increasing  $x$ , *i.e.*,  $x = 0.0025$  and  $0.005$ , the inhomogeneous grain structure still exists albeit the number of large grains, as well as the grain sizes, increase (Fig. 2b–d). Detailed analyses of the grain size distribution are given in Fig. S5.† Inhomogeneous distribution of large grains embedded in small grains when the doping level is extremely low is also observed in  $\text{NB}_{0.51}\text{T}$  ceramics doped with Zn, Sc, Al and Ga. Typical SEM images are shown in Fig. S6 (for Zn) and S7 (for Sc).†

Chemical compositions of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ceramics analysed by EDS on polished surfaces (without thermal-etching) are listed in Table 1. The cation ratios are normalised to 100% for ease of comparison. For this series, the nominal atomic percentages of Na and Bi are fixed at 24.88 and 25.37%, respectively, whereas those of Ti and Mg vary with increasing  $x$ . The measured values generally agree with the nominal values; however, the measured values are associated with large errors, indicating the elemental distribution, in particular, Mg, in the ceramics is inhomogeneous. It is noteworthy that the  $K\alpha$  line for Mg (1.25 keV) is close to that for Na (1.04 keV),<sup>1</sup> therefore, accurate acquisition of the atomic percentages of these cations is challenging. Nevertheless, the variation of atomic percentages of Ti and Mg with increasing  $x$  does provide qualified evidence that Mg is incorporated into  $\text{NB}_{0.51}\text{T}$ . EDS analysis on a thermally-etched Zn-doped  $\text{NB}_{0.51}\text{T}$  ( $x = 0.005$ ) is given in Table S1,† where an inhomogeneous elemental distribution of the dopant is also observed.

### Electrical properties

Complex impedance plane ( $Z^*$ ) plots and  $M'' - \log f$  spectroscopic plots measured at  $600\ ^\circ\text{C}$  in flowing nitrogen, air and oxygen for selected compositions are shown in Fig. 3. The  $Z^*$  plot for undoped  $\text{NB}_{0.51}\text{T}$ , Fig. 3a, shows a single arc. The associated capacitance of the arc is  $\sim 8 \times 10^{-11}\ \text{F cm}^{-1}$ , corresponding to a relative permittivity ( $\epsilon_r$ ) of  $\sim 900$ , which agrees with the value for paraelectric NBT at this temperature. The single arc in the  $Z^*$  plot for  $\text{NB}_{0.51}\text{T}$  therefore represents the bulk response, which is smallest in nitrogen and largest in oxygen, suggesting n-type electronic behaviour. This is in agreement with previous studies.<sup>1</sup> The corresponding  $M'' - \log f$  spectroscopic plots of undoped  $\text{NB}_{0.51}\text{T}$ , Fig. 3b, show a single

Table 1 Relative atomic percentage of cations in  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ceramics measured by EDS. Data were obtained by measurements on 5–10 randomly selected points on carbon-coated polished surfaces of the ceramics (without thermal-etching)

$x$	Na		Ti		Mg	
	Nominal	EDS	Nominal	EDS	Nominal	EDS
0	24.71 ± 0.40	24.88 ± 0.40	49.75	49.85 ± 0.41	0	NA
0.001	23.95 ± 1.21	23.95 ± 1.21	49.70	49.76 ± 0.93	0.05	0.15 ± 0.23
0.0025	23.97 ± 1.14	23.97 ± 1.14	49.63	49.49 ± 0.60	0.12	0.17 ± 0.21
0.005	23.36 ± 0.55	23.36 ± 0.55	49.50	49.35 ± 0.32	0.25	0.51 ± 0.51
0.01	23.65 ± 0.68	23.65 ± 0.68	49.25	48.66 ± 0.57	0.50	0.71 ± 0.46
0.015	24.16 ± 0.96	24.16 ± 0.96	49.00	48.18 ± 0.64	0.75	0.99 ± 0.41
0.02	24.46 ± 0.77	24.46 ± 0.77	48.76	48.06 ± 0.81	1.00	1.23 ± 0.59



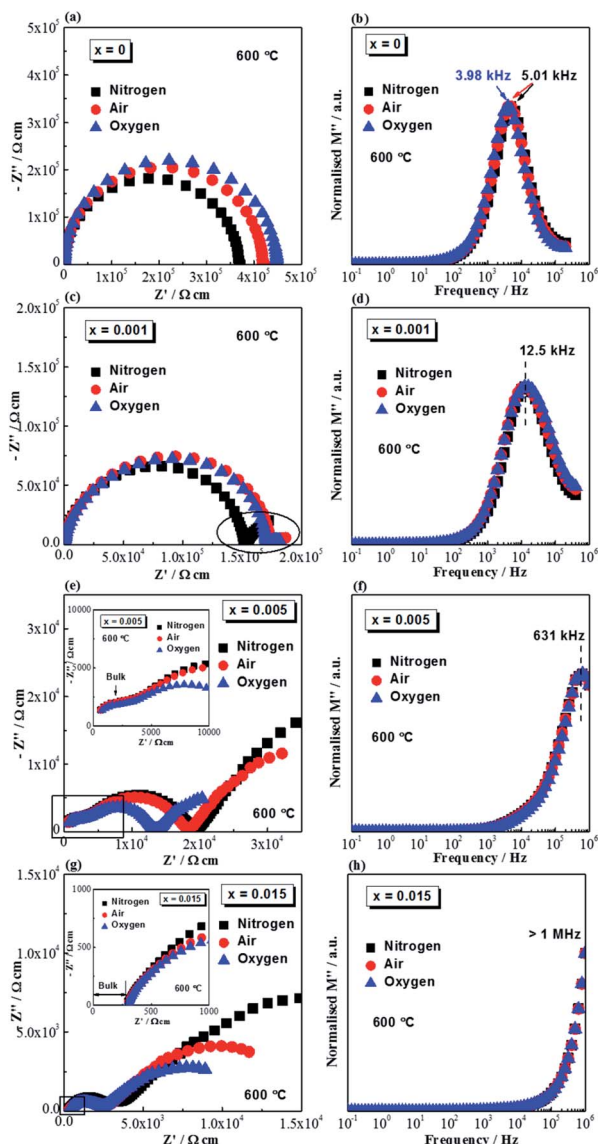


Fig. 3 Impedance spectroscopy data of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ( $x = 0, 0.001, 0.005$  and  $0.015$ ) ceramics at  $600\text{ }^\circ\text{C}$  in flowing nitrogen, air and oxygen in the frequency range from  $1\text{ MHz}$  to  $0.1\text{ Hz}$ . (a), (c), (e) and (g):  $Z^*$  plots for  $x = 0, 0.001, 0.005$  and  $0.015$ , respectively. Inset figures in (e) and (g) are an expanded view of the region in the rectangle. (b), (d), (f) and (h):  $M'' - \log f$  spectroscopic plots for  $x = 0, 0.001, 0.005$  and  $0.015$ , respectively. The numbers inside each figure indicate the frequency at the  $M''$  maxima.

Debye peak with a characteristic frequency,  $f_{\text{max}}$ , of  $5.01\text{ kHz}$  in air and oxygen and  $3.98\text{ kHz}$  in nitrogen. For  $x = 0.001$ , the  $Z^*$  plot (Fig. 3c) shows a distorted arc with an obvious low-frequency spike (indicated in the highlighted oval). The arc is smallest in nitrogen, suggesting the presence of n-type electronic conduction; the electrode spike is most prominent in nitrogen and least prominent in oxygen, suggesting the presence of oxide-ion conduction.  $\text{NB}_{0.51}\text{T}$  with  $0.1\%$  Mg-doping ( $x = 0.001$ ) therefore shows mixed electronic-ionic conduction behaviour. The corresponding  $M'' - \log f$  spectroscopic plots for this composition, Fig. 3d, show a broad peak with  $f_{\text{max}} = 12.5\text{ kHz}$ . The broad  $M''$  peak is an indication of either chemical or

microstructural inhomogeneity, which agrees with the information from SEM (Fig. 2a) and Table 1. With increasing doping level, for example  $x = 0.005$ ,  $Z^*$  plots (Fig. 3e) show two arcs with a large low frequency spike. The high frequency arc, corresponding to the bulk, is not dependent on  $p\text{O}_2$ , as shown by the inset figure. The associated capacitance for this high-frequency response is  $1.33 \times 10^{-10}\text{ F cm}^{-1}$ , corresponding to a permittivity value of  $\sim 1400$ , which agrees with the permittivity of bulk NBT at  $600\text{ }^\circ\text{C}$ . The medium frequency arc is smallest in oxygen and largest in nitrogen, suggesting a predominant p-type electronic conduction mechanism. The associated capacitance is  $1.37 \times 10^{-9}\text{ F cm}^{-1}$ , one order of magnitude higher than that of the high-frequency response, may be attributed to either a grain boundary response or a less conductive bulk phase (discussed later). The low frequency electrode spike is largest in nitrogen and smallest in oxygen, indicating the presence of oxide-ion conduction. Combining the above information, the bulk conduction of  $x = 0.005$  is dominated by oxygen ions. The corresponding  $M'' - \log f$  spectroscopic plot, Fig. 3f, shows a  $p\text{O}_2$ -independent peak at  $f_{\text{max}} = 631\text{ kHz}$ . For  $x = 0.015$ ,  $Z^*$  plots, Fig. 3g, are dominated by a grain boundary response and the electrode effect. An expanded view of the high frequency range (inset of Fig. 3g) shows a  $p\text{O}_2$ -independent intercept with the  $Z'$ -axis, corresponding to the resistance of the bulk, suggesting an oxide-ion conduction mechanism. The  $M''$  peak is beyond the highest measured frequency, therefore  $f_{\text{max}}$  exceeds  $1\text{ MHz}$ , Fig. 3h. The above information from impedance spectroscopy indicates that, with very low levels of Mg doping, it is possible to change the electrical conduction mechanism of  $\text{NB}_{0.51}\text{T}$  from n-type electronic (type III) to mixed electronic-ionic (type II) and finally to oxide-ion conduction (type I).

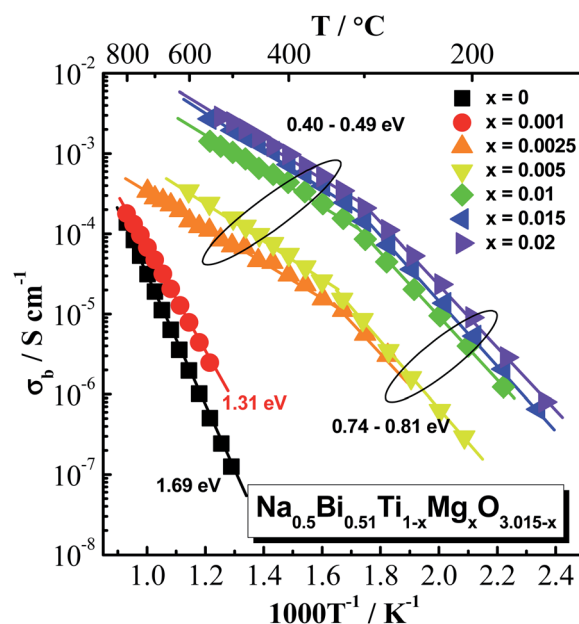


Fig. 4 Arrhenius plot for bulk conductivity,  $\sigma_b$ , of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ( $x = 0, 0.001, 0.0025, 0.005, 0.01, 0.015$  and  $0.02$ ) ceramics measured in air. Numbers in eV are the activation energies associated with bulk conduction.

Arrhenius plots of bulk conductivity,  $\sigma_b = 1/R_b$ , for  $\text{Na}_{0.5-x}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ( $x = 0, 0.001, 0.0025, 0.005, 0.01, 0.015$  and  $0.02$ ) ceramics over a range of temperatures are shown in Fig. 4. Based on the magnitude of  $\sigma_b$ , these ceramics can be divided into three groups: (1)  $x = 0$  and  $0.001$ ,  $\sigma_b$  values are very low (so they can be measured only at high temperatures). In the temperature range between  $500$  and  $800$  °C,  $\sigma_b - 1000T^{-1}$  shows a linear relationship with  $E_a$  values of  $1.69$  eV for  $x = 0$  and  $1.31$  eV for  $x = 0.001$ ; (2)  $x = 0.0025$  and  $0.005$ , show intermediate  $\sigma_b$  values.  $\sigma_b - 1000T^{-1}$  relationships show a change in  $E_a$  from  $\sim 0.8$  eV below  $300$  °C to  $\sim 0.4$  eV above  $300$  °C; (3)  $x \geq 0.01$ ,  $\sigma_b$  values are high, and also show a change in  $E_a$  at  $\sim 300$  °C. The change in  $E_a$  at  $\sim 300$  °C has been discussed in previous studies and is attributed to the coexistence of rhombohedral and tetragonal NBT polymorphs between  $250$  and  $400$  °C (ref. 8) or as a combination of defect associates and polymorphic phase transitions.<sup>9</sup> As a change in  $E_a$  at  $\sim 300$  °C is a characteristic of type I NBT, the data in Fig. 4 suggests the bulk conduction of  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ceramics with  $x \geq 0.0025$  is predominantly by migration of oxygen ions.  $\sigma_b$  Arrhenius plots for other acceptor-doped  $\text{NB}_{0.51}\text{T}$  show similar behaviour and are given in ESI, Fig. S8–S11.†

Oxygen-ion transport number,  $t_{\text{ion}}$ , as a function of  $x$  is shown in Fig. 5. Undoped  $\text{NB}_{0.51}\text{T}$  ( $x = 0$ ) has  $t_{\text{ion}}$  close to zero, suggesting a predominant electronic conduction mechanism;  $x = 0.001$  has  $t_{\text{ion}} \sim 0.35$ , suggesting mixed electronic–ionic conduction behaviour;  $x \geq 0.025$  have  $t_{\text{ion}} > 0.9$ , suggesting predominant oxide-ion conduction behaviour. These  $t_{\text{ion}}$  values further confirm the information obtained from the  $p\text{O}_2$  dependence of  $\sigma_b$  and the  $\sigma_b - 1000T^{-1}$  relationship that very low levels of acceptor doping (*i.e.*,  $0.25$  and  $0.5\%$ ) can change the bulk conduction of  $\text{NB}_{0.51}\text{T}$  from electronic to ionic, although the magnitude of  $\sigma_b$  is below  $10^{-3}$   $\text{S cm}^{-1}$  and resides in the type II region (Fig. 5).

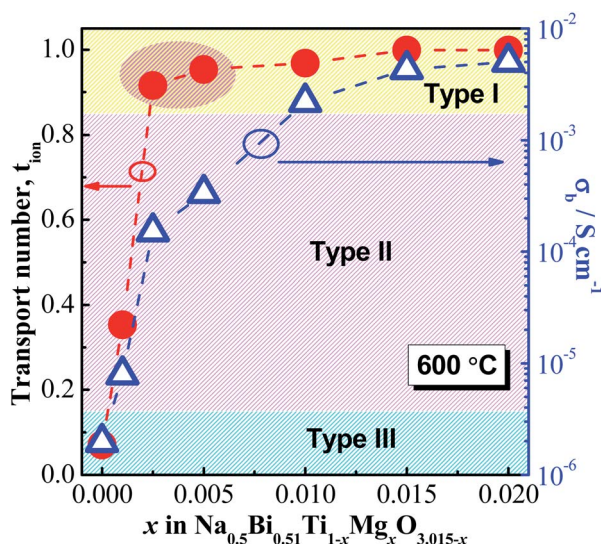


Fig. 5 Oxygen-ion transport number,  $t_{\text{ion}}$ , and bulk conductivity,  $\sigma_b$ , at  $600$  °C versus  $x$ .

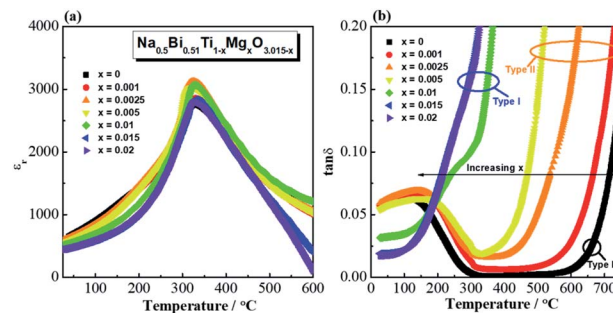


Fig. 6 Dielectric spectroscopy for  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ( $x = 0, 0.001, 0.0025, 0.005, 0.01, 0.015$  and  $0.02$ ) ceramics: (a) permittivity at  $1$  MHz versus temperature and (b) dielectric loss,  $\tan \delta$ , ( $1$  MHz) versus temperature.

### Dielectric properties

Permittivity-temperature ( $\epsilon_r - T$ ,  $1$  MHz) and dielectric loss-temperature ( $\tan \delta - T$ ,  $1$  MHz) profiles for  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ( $x = 0, 0.001, 0.0025, 0.005, 0.01, 0.015$  and  $0.02$ ) ceramics are shown in Fig. 6. Incorporation of  $\text{Mg}^{2+}$  into  $\text{NB}_{0.51}\text{T}$  does not change the permittivity maximum or the temperature of the permittivity maximum,  $T_m$  (Fig. 6a) but it has a significant effect on the  $\tan \delta - T$  profile (Fig. 6b).  $\text{NB}_{0.51}\text{T}$  ( $x = 0$ ) shows very low  $\tan \delta$  over a wide temperature range ( $< 0.02$  between  $300$  and  $700$  °C).  $x = 0.001, 0.0025$  and  $0.005$  show low  $\tan \delta$  in a narrower temperature range and a steep rise between  $350$  and  $700$  °C. With high doping levels, *i.e.*,  $x = 0.01, 0.015$  and  $0.02$ ,  $\tan \delta$  shows a sharp rise with increasing temperature and it exceeds  $0.2$  at  $\sim 350$  °C. With increasing  $\text{Mg}$  doping level, the  $\tan \delta - T$  relationship of  $\text{NB}_{0.51}\text{T}$  presents a shift from type III behaviour to type II and finally to type I. Similar dielectric behaviour is observed for other B-site acceptor-doped  $\text{NB}_{0.51}\text{T}$  ceramics as shown in Fig. S12–S15.†

### Comparison of various dopants

$\sigma_b$  for  $\text{NB}_{0.51}\text{T}$  with various acceptor dopants and doping levels measured at  $500$  °C in air are shown in Fig. 7. For all the acceptor-type dopants investigated in this work, very low levels of doping can significantly enhance  $\sigma_b$  of  $\text{NB}_{0.51}\text{T}$  by more than three orders of magnitude. For the divalent ions, Fig. 7a, doping

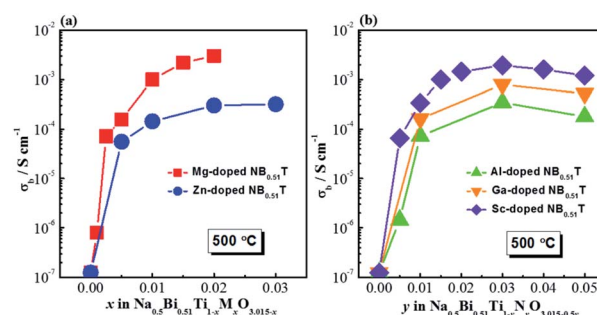


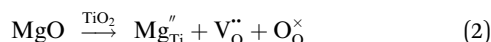
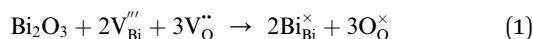
Fig. 7 Bulk conductivity,  $\sigma_b$ , for  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{TiO}_{3.015}$  with various acceptor dopants and doping levels: (a) divalent dopants  $\text{Mg}^{2+}$  and  $\text{Zn}^{2+}$ ; (b) trivalent dopants  $\text{Al}^{3+}$ ,  $\text{Ga}^{3+}$  and  $\text{Sc}^{3+}$ .

NB<sub>0.51</sub>T with Mg shows higher  $\sigma_b$  than that with Zn; for trivalent dopants, Fig. 7b, the highest  $\sigma_b$  in NB<sub>0.51</sub>T occurs with Sc doping, the lowest with Al and intermediate with Ga.

## Discussion

### Synergistic effect of defect chemistry and ceramic microstructure

Defect chemistry in B-site acceptor-doped NB<sub>0.51</sub>T, using Mg as an example, can be described by the following two defect equations,



in which eqn (1) describes consumption of oxygen vacancies by excess Bi<sub>2</sub>O<sub>3</sub> on the A-site, and eqn (2) represents creation of oxygen vacancies by B-site acceptor doping *via* an ionic compensation mechanism. When oxygen vacancies generated by acceptor doping on the B-site exceed those consumed by excess Bi<sub>2</sub>O<sub>3</sub> on the A-site, the overall effect is creation of oxygen vacancies in NB<sub>0.51</sub>T.

As the presence of oxygen vacancies is a pre-requisite for oxide-ion conduction,  $\sigma_b$  and  $t_{\text{ion}}$  of NBT-based materials usually exhibit a strong dependence on the nominal oxygen

deficiency,  $\delta$ , with an “onset” transition between low  $\sigma_b$  ( $<10^{-5}$  S cm<sup>-1</sup>) and  $t_{\text{ion}}$  ( $<0.1$ ), to high  $\sigma_b$  ( $>10^{-3}$  S cm<sup>-1</sup>) and  $t_{\text{ion}}$  ( $>0.9$ ) near  $\delta = 0$ , as presented by the open circles in Fig. 8. If starting from a Bi-excess NBT, *i.e.*, Na<sub>0.5</sub>Bi<sub>0.51</sub>Ti<sub>0.985</sub>O<sub>3.015</sub>, acceptor-doping such as Mg<sup>2+</sup> on the Ti<sup>4+</sup> site will give a chemical formula of Na<sub>0.5</sub>Bi<sub>0.51</sub>Ti<sub>1-x</sub>Mg<sub>x</sub>O<sub>3.015-x</sub>. Based on the previous findings of the  $\sigma_b - \delta$  and  $t_{\text{ion}} - \delta$  relationship in Fig. 8, a transition from insulating to conducting at  $x = 0.015$  may be expected; however, it is surprising to notice that extremely low levels of Mg<sup>2+</sup> (*i.e.*,  $x \leq 0.005$ ) can introduce considerable levels of oxide ion conduction into NB<sub>0.51</sub>T and change the conduction mechanism from insulating to ionic-conducting based on  $t_{\text{ion}}$  (*i.e.*,  $t_{\text{ion}} > 0.9$  for  $x = 0.0025$ ), as shown by the solid red spheres in Fig. 8. The unexpected discovery that acceptor-doping in NB<sub>0.51</sub>T shifts the onset transition in oxygen deficiency to  $\delta < 0$  suggests an additional mechanism, other than the defect chemistry induced by acceptor doping, should be considered.

An important microstructural feature of acceptor-doped NB<sub>0.51</sub>T with low doping levels is the inhomogeneous and random distribution of large grains in a small grained matrix, presumably based on a variation in the distribution of the low level of acceptor dopants *via* the solid-state reaction route used to prepare the ceramics. This motivated us to explore the possible impact from the ceramic microstructure on the conductivity of the ceramics. Conductivity values for NBT-based ceramics are summarised from literature and plotted as a function of average grain size in Fig. 9. There is a critical grain size of  $\sim 3.5$   $\mu\text{m}$ , below which NBT ceramics have low conductivity and above which they have high conductivity.

Combining effect of oxygen deficiency,  $\delta$ , and grain size,  $d$ , on conductivity is illustrated by the contour map in Fig. 10. In general, the high conductivity region (orange and red colours) lies in the top-right where  $\delta$  has a large, positive value and  $d$  is large, and the low conductivity region (blue colour) lies in the bottom-left where  $\delta$  is negative and  $d$  is small. This suggests that in most cases, conductivity of NBT-based materials is determined by oxygen deficiency; however, there are two unexpected regions, as marked by the dashed ellipses. Region (1):  $d > 3.5$   $\mu\text{m}$ , conductivity increases with increasing grain size even if  $\delta <$

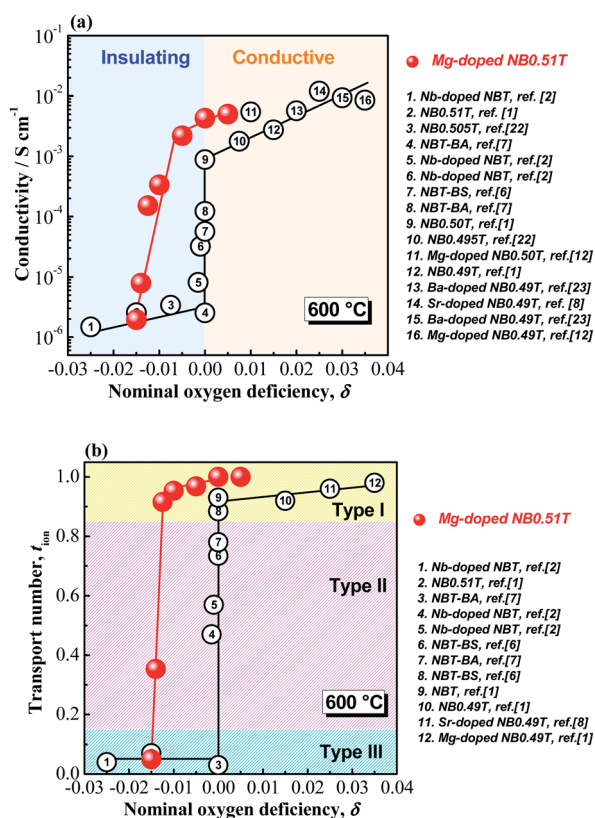


Fig. 8 (a) Bulk conductivity,  $\sigma_b$  and (b) oxide-ion transport number,  $t_{\text{ion}}$  of NBT-based materials as a function of nominal oxygen deficiency,  $\delta$ . The solid spheres represent the data for Mg-doped NB<sub>0.51</sub>T in this work, and the open circles are data from literature.

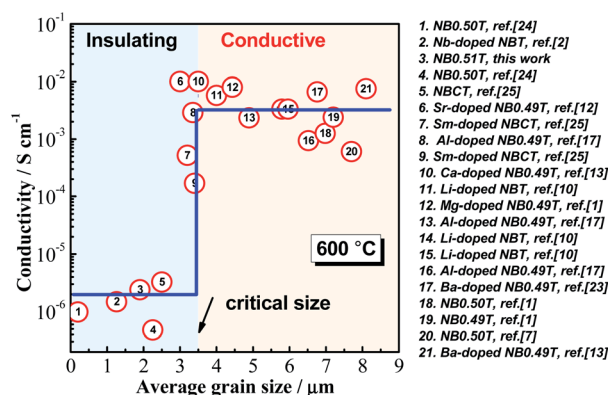


Fig. 9 Conductivity-average grain size relationship of non-stoichiometric and doped NBT ceramics.



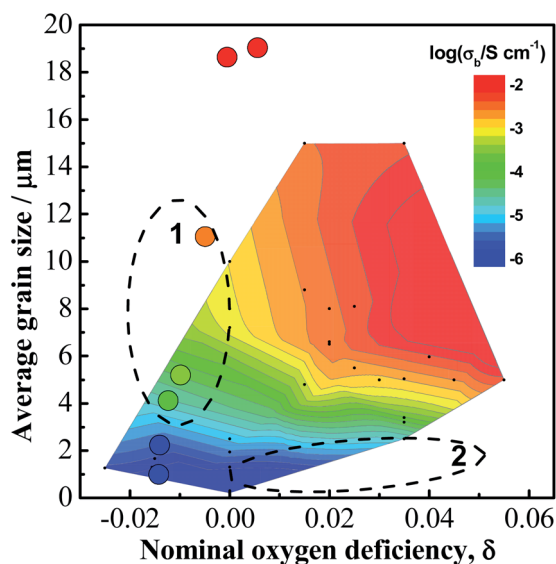


Fig. 10 A contour map showing the dependence of bulk conductivity (at 600 °C) on nominal oxygen deficiency and average grain size. The contour map is plotted based on data collected from references listed in Fig. 8 and 9. The filled circles are experimental data from this work.

0; region (2):  $d < 3.5 \mu\text{m}$ , conductivity remains low although  $\delta > 0$ . This suggests that in these two regions, conductivity is determined by the grain size rather than oxygen deficiency. For  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  investigated in this work, three compositions  $x = 0.0025, 0.005$  and  $0.01$ , are within region (1).

As grain size has a large impact on the conductivity, we plot the statistical grain size distribution for each composition, as shown in Fig. S5.† With increasing  $x$  there is an increase in the average grain size, however there is also an increasingly broader grain size distribution. According to the conductivity-grain size

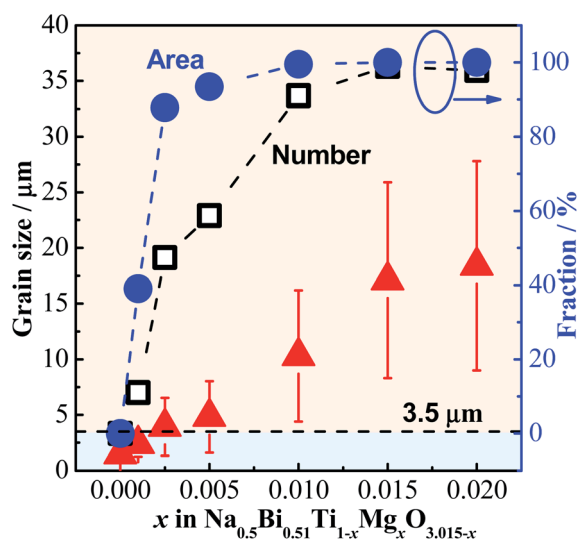


Fig. 11 Average grain size (filled triangles), number (open squares) and area (filled cycles) fractions of large grains ( $d > 3.5 \mu\text{m}$ ) as a function of  $x$ . The horizontal dash line represents the critical grain size for the insulating-conductive transition.

relationship in Fig. 9,  $d = 3.5 \mu\text{m}$  is used as the critical grain size and the relative fraction of grains with  $d > 3.5 \mu\text{m}$  (defined as large grains) is calculated and presented in Fig. 11, where a rapid increase in the number fraction of large grains from 0 to  $\sim 90\%$  can be observed between  $x = 0-0.01$ . This fraction approaches 100% for  $x = 0.015$  and  $0.02$ . Although the fraction of large grains is calculated based on two-dimensional SEM images and thus may deviate from the three-dimensional volume fraction, it still shows a trend that the number of large grains increases with increasing  $x$ . Furthermore, the area fraction in 2D should be similar to the volume fraction in 3D in the case of randomly distributed large grains and a randomly selected area for observation according to the theory of quantitative stereology.<sup>26</sup>

Combining the information from Fig. 9–11,  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  ceramics with low levels of Mg-doping ( $x = 0.001, 0.0025, 0.005$  and  $0.01$ ) consist of two types of grains:  $d > 3.5 \mu\text{m}$  (large grains, high conductivity) and  $d < 3.5 \mu\text{m}$  (small grains, low conductivity). For impedance spectroscopy measurements, the electrical current is going to take the path of least resistance and thus favour the larger conductive grains and avoid the smaller, resistive grains. Impedance data are therefore dominated by the conductive phase (large grains) when percolation is achieved.

Electrical conductivity of a composite with a random distribution of two phases can usually be predicted by a percolation theory. When the volume fraction of the conductive phase reaches a certain threshold, typically  $\sim 16\%$ ,<sup>27</sup> the conductive phase can interconnect in the composite structure forming a conduction path that results in a dramatic increase in the effective conductivity of the sample. To further discuss the possible impact from the two-phase microstructure, finite element modelling (FEM) was employed to simulate conductivity data using ElCer.<sup>21</sup>

First a 3D geometric model is established for each value of  $x$  using a Voronoi tessellation process to create 512 grains. Adopting a standard Voronoi tessellation<sup>21</sup> is insufficient to replicate this microstructure here, as the algorithm would divide up the space between the initial seed points equally. As such the models generated would produce a normal distribution of grain sizes, where the smaller grains would surround the larger one and grow in size as they near them. To overcome this, we use a feature in Voro++<sup>28</sup> known as radical Voronoi tessellation. This has been used previously to successfully model the percolation effects in composite materials.<sup>29</sup> Each discretized seed point is weighted with a value. These weights were then randomised, generating a special distribution of larger and smaller grains throughout the model. The distribution of grain areas is created such that the fraction of large grains ( $d > 3.5 \mu\text{m}$ ) matches the values obtained from SEM as given by the blue filled symbols in Fig. 11. An example of one of these models is shown in Fig. 12a for  $x = 0.010$ . Three electrical models for each geometrical model were investigated based on a two-phase mixture where the materials properties of conductivity and permittivity were assigned as  $\sigma_1$  and  $\epsilon_1$  for the insulating phase and  $\sigma_2$  and  $\epsilon_2$  for the conductive phase. The area fraction of large grains ( $d > 3.5 \mu\text{m}$ ) was assigned as the fraction of





Fig. 12 (a) A 3D geometric model for finite element simulations; (b) the relationship between Mg content, and the upper and lower conductivity limits. The lower limit is assigned to  $\sigma_1$ , the upper limit is modified and assigned to  $\sigma_2$  through a TM (threshold model), LM (linear model) and AM (area model). (c) Calculated dc conductivity versus  $x$  using three separate conductivity profile models TM, LM and AM, in comparison with experimental results (Exp.).

conductive grains ( $\sigma_2$ ). In all three models,  $\epsilon_1$  and  $\epsilon_2$  were fixed at a value of 1000 (for  $\epsilon$ ) and  $\sigma_1$  assigned  $1.8 \times 10^{-6} \text{ S cm}^{-1}$ . The magnitude of  $\sigma_2$  for each value of  $x$  was based on three scenarios of conductivity (explained below) but in each case had an upper limit of  $4 \times 10^{-3} \text{ S cm}^{-1}$ . The lower and upper limits of conductivity for the FEM analysis were based on the experimental results shown in Fig. 5 for  $x = 0$  ( $1.8 \times 10^{-6} \text{ S cm}^{-1}$ ) and  $x = 0.015$  ( $4 \times 10^{-3} \text{ S cm}^{-1}$ ), respectively.

The first is a threshold model (TM). Any grain with diameter exceeding the threshold of  $3.5 \mu\text{m}$  is assumed to be conducting and set as  $\sigma_2 = 4 \times 10^{-3} \text{ S cm}^{-1}$  with all other grains assumed to be insulating and therefore set as  $\sigma_1 = 1.8 \times 10^{-6} \text{ S cm}^{-1}$ , as shown by the horizontal lines in Fig. 12b. The second is based a linear model (LM) where the grain conductivity (on a logarithmic scale) is a linear interpolation of the Mg content,  $x$ , ranging from  $\sigma_1 = 1.8 \times 10^{-6} \text{ S cm}^{-1}$  for  $x = 0$  to  $\sigma_2 = 4 \times 10^{-3} \text{ S cm}^{-1}$  for  $x = 0.015$ , as shown by the filled green symbols in Fig. 12b. The third model is an area fraction model (AM) that maps  $\sigma_2$  (on a logarithmic scale) to the area fraction of the large grains shown by the filled blue symbols in Fig. 11. As shown, this rises dramatically from the lower limit for  $x = 0$  to  $\sim 2 \times 10^{-3} \text{ S cm}^{-1}$  for  $x \sim 0.0015$  but then varies slowly with  $x$  to the upper limit of  $4 \times 10^{-3} \text{ S cm}^{-1}$  for  $x = 0.015$ , given by the filled red triangles in Fig. 12b. For each model we start with all grains set initially as  $\sigma_1$ , and then randomly assign a proportion of them the properties of  $\sigma_2$  to represent the specific level of Mg content ( $x$ ). To ensure the order of the random selection is not affecting the results we performed this for 5 separate times. The averages of any given set, and any individual results were found to be within 5% of each other.

The dc conductivity obtained from the simulations of the three different models for each value of  $x$  was estimated from the low frequency intercept on the  $Z'$  axis of  $Z^*$  plots (not shown), Fig. 12c. Experimental values showing the two orders of magnitude increase in conductivity up to  $x \sim 0.003$  followed by a near linear increase in conductivity to the upper limit at  $x = 0.015$  is included in Fig. 12c (black and yellow filled squares) to allow a comparison with the simulated values from the various FEM models. For the TM, the conductivity rises by over three orders of magnitude at very low  $x$ , levelling-off to the upper conductivity value at  $x \sim 0.0015$ . This model dramatically overestimates the observed experimental trend. This can be attributed to  $\sigma_2$  generating a percolative pathway of less resistive grains through the model. For the LM, no percolation is observed and a linear rise in conductivity with  $x$  is observed; however, it also does not correlate with the experimental trend and in this case underestimates the observed experimental trend. As a consequence, neither a simple percolation model or an averaging of grain conductivity based on Mg content can explain the experimental trend. Although the AM also overestimates conductivity there is closer correlation to the experimental trend, especially in the range  $0 < x < 0.002$  where the two orders of magnitude increase in experimental conductivity is observed. In the FEM modelling grain boundary effects were not considered and may be a possible reason for the deviation between the FEM and experimental results. Nevertheless, the FEM results do support a link between the evolving microstructure at low  $x$  with the dramatic increase in conductivity observed from impedance spectroscopy.

Finally, it is worth mentioning that the connectivity of the large grains plays a critical role on the electrical conduction pathways. If the conductive, large grains are surrounded by insulating, small grains, the electrical current can be blocked and therefore result in low conductivity. For our conventionally sintered ceramics, it is reasonable to assume a random distribution for these two types of grains. The experimental results and FEM simulations presented here support the conclusion that percolation of large grains can be achieved at very low doping levels.

### Comparison of dopants, $\text{Mg}^{2+}$ , $\text{Zn}^{2+}$ , $\text{Sc}^{3+}$ , $\text{Ga}^{3+}$ and $\text{Al}^{3+}$

In this work five acceptor-type dopants,  $\text{Mg}^{2+}$ ,  $\text{Zn}^{2+}$ ,  $\text{Sc}^{3+}$ ,  $\text{Ga}^{3+}$  and  $\text{Al}^{3+}$  were selected to partially replace  $\text{Ti}^{4+}$  in a nominally Bi-excess sodium bismuth titanate,  $\text{NB}_{0.51}\text{T}$ . All five dopants have a similar effect on the electrical properties of  $\text{NB}_{0.51}\text{T}$  such that very low levels of doping can induce considerable levels of oxide-ion conduction due to the inhomogeneous distribution of large and small grains in the microstructure. Comparing the divalent ions, at the same doping level,  $\text{Mg}^{2+}$  is more effective in enhancing the bulk conductivity of  $\text{NB}_{0.51}\text{T}$  than  $\text{Zn}^{2+}$  (Fig. 7a). For trivalent ions, the ability to achieve high conductivity in  $\text{NB}_{0.51}\text{T}$  follows the order  $\text{Sc}^{3+} > \text{Ga}^{3+} > \text{Al}^{3+}$  (Fig. 7b). A summary of the physical properties of these dopant ions is listed in Table 2. Plots of the bulk conductivity of these acceptor-doped  $\text{NB}_{0.51}\text{T}$  with a nominal oxygen deficiency  $\delta = 0$ , together with that of  $\text{NB}_{0.50}\text{T}$ , as a function of various physical parameters of the

Table 2 Physical properties of dopant and host ions. Bonding-strength with oxygen and polarisability values are from ref. 30 and 31, respectively

Dopant	Charge	Ionic radius/ $\text{\AA}$	M–O bond strength/kJ mol <sup>-1</sup>	Electro-negativity	Polarisability/ $\text{\AA}^3$
Mg	+2	0.72	$358.2 \pm 7.2$	1.31	1.32
Zn	+2	0.74	$\leq 250$	1.65	2.04
Sc	+3	0.745	$671.4 \pm 1.0$	1.36	2.81
Ga	+3	0.62	$374 \pm 21$	1.81	1.50
Al	+3	0.535	$501.9 \pm 10.6$	1.61	0.79
Ti	+4	0.605	$666.5 \pm 5.6$	1.54	2.93

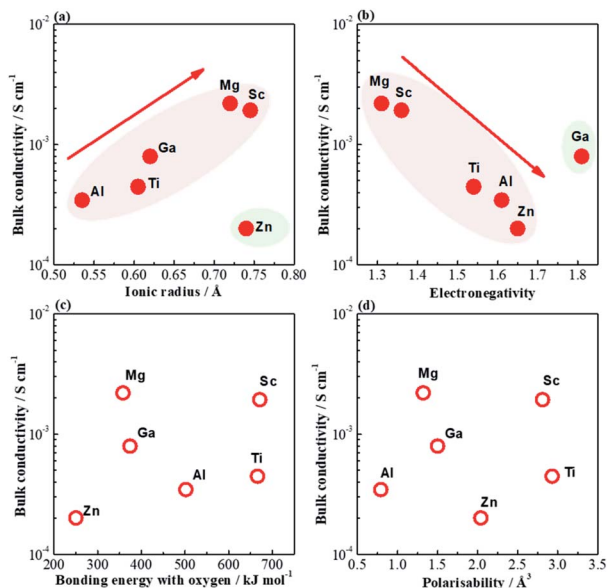


Fig. 13 Bulk conductivity as a function of (a) ionic radius, (b) electronegativity, (c) bonding energy with oxygen and (d) polarisability of dopant ions.

dopant ions are shown in Fig. 13. Ionic radius and electronegativity have a notable effect *i.e.*, high  $\sigma_b$  can be achieved with dopants with large ionic radius and low electronegativity but both have exceptions (Fig. 13a and b). On the other hand,  $\sigma_b$  shows no systematic variation with the bonding strength with oxygen and polarisability of these B-site dopants (Fig. 13c and d).

Among all the acceptor-doped  $\text{NB}_{0.51}\text{T}$  ceramics in this study, the highest  $\sigma_b$  value ( $3 \text{ mS cm}^{-1}$  at  $500^\circ\text{C}$ ) is obtained in  $\text{Na}_{0.5}\text{Bi}_{0.51}\text{Ti}_{1-x}\text{Mg}_x\text{O}_{3.015-x}$  for  $x = 0.02$ , which is slightly lower than the highest  $\sigma_b$  previously observed in Sr-doped  $\text{NB}_{0.49}\text{T}$  ( $5.6 \text{ mS cm}^{-1}$  at  $500^\circ\text{C}$ ). It can be concluded therefore that high oxide-ion conductivity can also be achieved by B-site acceptor-doping in an insulating  $\text{NB}_{0.51}\text{T}$ .

## Conclusion

The effect of acceptor-doping on the electrical conductivity and conduction mechanism of nominally Bi-excess sodium bismuth titanate,  $\text{NB}_{0.51}\text{T}$  ceramics is investigated by impedance spectroscopy and electromotive force measurements. Five acceptor-

type dopants including  $\text{Mg}^{2+}$ ,  $\text{Zn}^{2+}$ ,  $\text{Sc}^{3+}$ ,  $\text{Ga}^{3+}$  and  $\text{Al}^{3+}$  were selected to partially replace  $\text{Ti}^{4+}$  in  $\text{NB}_{0.51}\text{T}$ . Acceptor-doping on the Ti-site changes the electrical behaviour of  $\text{NB}_{0.51}\text{T}$  from insulating (type III) to mixed ionic–electronic conduction (type II) to oxide-ion conducting (type I). Most importantly, it is surprising to find that extremely low levels of acceptor-type dopants can introduce considerable levels of oxide-ion conduction into  $\text{NB}_{0.51}\text{T}$ , *i.e.*, 0.5% Mg-doping can enhance the bulk conductivity of  $\text{NB}_{0.51}\text{T}$  more than 3 orders of magnitude and the oxide-ion transport number from  $<0.1$  for  $\text{NB}_{0.51}\text{T}$  to  $>0.9$  at  $600^\circ\text{C}$ . Furthermore, acceptor doping in  $\text{NB}_{0.51}\text{T}$  changes the “onset” nominal oxygen deficiency for the insulating–conducting transition from  $\delta = 0$  to  $\delta < 0$ . The intriguing electrical behaviours in acceptor-doped  $\text{NB}_{0.51}\text{T}$  dielectrics is attributed to the ceramic microstructure. When the doping level is extremely low (*i.e.*, 0.1% and 0.5% for divalent and trivalent dopants, respectively),  $\text{NB}_{0.51}\text{T}$  ceramics develop an inhomogeneous microstructure with randomly distributed large grains embedded in a small grained matrix. Such ceramics can be approximated to a two-phase composite with large grains ( $d > 3.5 \mu\text{m}$ ) as a non-percolative conductive phase and small grains ( $d < 3.5 \mu\text{m}$ ) as the insulating phase. Statistics on the grain size show the fraction of the conductive, large grains in the ceramic agrees with the oxide-ion transport number. The electrical two-phase model is also supported by finite element modelling. Unlike that in  $\text{NB}_{0.50}\text{T}$  and  $\text{NB}_{0.49}\text{T}$  oxide-ion conductors, electrical conduction behaviour in acceptor-doped  $\text{NB}_{0.51}\text{T}$  is a combined effect from defect chemistry and ceramic microstructure.

This study not only confirms the effectiveness of using acceptor-doping to obtain high-oxide ion conductivity but also points out the significance of the ceramic microstructure on the electrical conduction behaviour in NBT-based materials. Furthermore, together with the previously reported results on acceptor-doped  $\text{NB}_{0.50}\text{T}$  and  $\text{NB}_{0.49}\text{T}$ , it can be summarized that dopants with large ionic radii are generally beneficial to oxide-ion conduction in NBT-based materials albeit Zn being an exception. This can be used as a criterion for selecting appropriate dopants to meet the electrical property requirements for different applications.

## Conflicts of interest

There are no conflicts to declare.

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